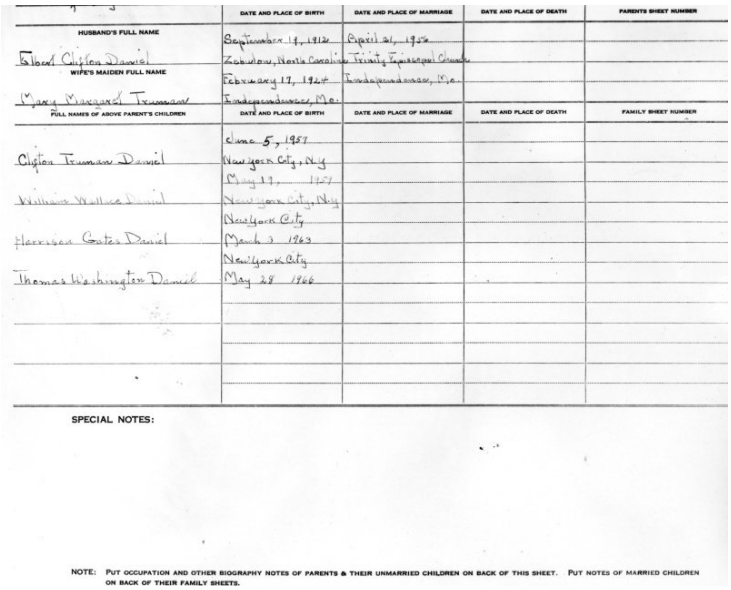
Family tree of the Harry S. Truman ancestral lines: Elbert Clifton Daniel and Mary Margaret Truman



HUSBAND'S FULL NAME	DATE AND PLACE OF BIRTH	DATE AND PLACE OF MARRIAGE	DATE AND PLACE OF DEATH	PARENTS SHEET NUMBER
Elbert Clifton Daniel	September 14, 1912 Zebulon, North Carolina	April 26, 1938 Trinity Episcopal Church		
WIFE'S MAIDEN FULL NAME				
Mary Margaret Truman	February 17, 1924 Independence, Mo.	Independence, Mo.		
FULL NAMES OF ABOVE PARENT'S CHILDREN	DATE AND PLACE OF BIRTH	DATE AND PLACE OF MARRIAGE	DATE AND PLACE OF DEATH	FAMILY SHEET NUMBER
Clifton Truman Daniel	June 5, 1957 New York City, N.Y.			
William Wallace Daniel	May 13, 1959 New York City, N.Y.			
Harrison Gates Daniel	New York City March 3 1963			
Thomas Washington Daniel	New York City May 28 1966			

SPECIAL NOTES:

NOTE: PUT OCCUPATION AND OTHER BIOGRAPHY NOTES OF PARENTS & THEIR UNMARRIED CHILDREN ON BACK OF THIS SHEET. PUT NOTES OF MARRIED CHILDREN ON BACK OF THEIR FAMILY SHEETS.

Description

Chart of family tree of the Harry S. Truman ancestral lines: Elbert Clifton Daniel and Mary Margaret Truman (daughter of President Truman). These genealogical charts were prepared by family historian Mary Ethel Noland, a cousin of President Truman.

Date(s)

Accession Number
72-3399

6-1/2x9-1/2 inches Black & White

Related Collection Noland, Mary Ethel Papers

Keywords Children of presidents Presidential family Presidential personal matters

HST Keywords Truman - Margaret - Family - Daniel, Clifton

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